

Transient absorption and laser gain in e-beam-excited Ar/Kr/NF₃(F₂ + N₂) gas mixtures

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Abstract

Newly developed erosion-plasma-source probe technique has been applied for virtually single shot recording of absorption/fluorescence spectra in the 190–510 nm spectral range of e-beam-excited Ar/Kr/NF₃(F₂ + N₂) mixtures. The e-beam excitation rate of about 1 MW/cm³ is typical of large-volume rare-gas halide lasers. It is experimentally observed that, in Kr/F₂ and Ar/F₂ mixtures, fluorescence and absorption spectra of Rg₂F species are shifted with respect to each other in the opposite direction. Continuous absorption spectrum of Ar₂F excimer is reported, as far as we know, for the first time in the refereed literature. Strong overlapping between the fluorescence and absorption spectra of Ar₂F is responsible for absence of lasing on Ar₂F molecule. Absorption spectrum of Kr₂F excimer is recorded in pure form using the mixture (Ne/Kr/F₂) with no alternative broadband absorber. Minor additive of nitrogen to Ar/Kr/F₂ mixture or use of NF₃ instead of F₂ has been found to result in broadband optical amplification centered at $\lambda \sim 460$ nm. The maximum optical gain is estimated as about 0.1 ± 0.05 m⁻¹.

Keywords: Gain measurement; Rare-gas halide lasers; Transient absorption probe; UV-visible molecular spectra

1. INTRODUCTION

Interest to studying transient absorption in mixtures of rare gases with fluorine (or fluorine donor) stems from practical importance of e-beam-pumped ultraviolet (UV)-blue excimer lasers on rare-gas halides. One of those, a high-power UV KrF laser with Ar/Kr/F₂ gain mixture, has attracted renewed interest as a possible driver for the inertial fusion energy (IFE) (Obenschain *et al.*, 2009). An attractive option seems to be using a broadband Kr₂F transition in the dark blue range (see, e.g., Molchanov (2006) and Huestis *et al.* (1984)) which allows amplification of ultra-short pulses, e.g., second harmonic of femtosecond Ti:sapphire laser, being of interest for the fast-ignition (Basov *et al.*, 1992; Tabak *et al.*, 1994), and shock-ignition (Sherbakov, 1983; Betti *et al.*, 2007) IFE approaches. However, such feasibility is vulnerable to photoabsorption in the gain medium, which affects extraction efficiency from the gain medium (Molchanov, 1988; Zvorykin *et al.*, 2007). Available experimental literature data on transient absorption in rare gas mixtures with fluorine are mainly related to

measurements at a few discrete wavelengths, whereas the data on continuous absorption spectra are far from completeness.

In this paper, we examine the origins of transient absorption and effects of adding fluorine and nitrogen to rare gases and their mixtures, as well as using NF₃ as a fluorine donor upon UV-visible absorption and fluorescence spectra under e-beam excitation of up to 1 MW/cm³ typical of large-scale excimer laser conditions. This laser-oriented study employs our results (Levchenko *et al.*, 2010a), in which were recorded the absorption spectra of e-beam excited Ne, Ar, and Kr and their binary mixtures in the 190–510 nm spectral range.

2. EXPERIMENT

Experimental setup and absorption probe technique are described in detail in Levchenko *et al.* (2010a, 2010b). In brief, the experiments are performed at the preamplifier module of GARPUN laser facility (Zvorykin *et al.*, 2001) using a 1-m-long gas chamber pumped by a 90-ns-long relativistic e-beam with peak current density of about 50 A/cm². To improve e-beam-pumping uniformity, a tantalum electron backscattering reflector shaped as cylindrical segment was placed in the chamber about 7 cm behind the foil. Prior to using rare gas-fluorine mixtures, the gas chamber is

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passivated with fluorine-rich mixtures; the gases of high- or very-high-purity grade are used. The absorption spectra are recorded using a charge-coupled device (CCD)-based spectrometer and a pulsed source of broadband probing radiation self-synchronized with e-beam pulse. The same KrF discharge-pumped laser is used both for triggering the e-beam pulse and production of an erosion plasma plume on the target (made of Cu or Teflon) acting as a quasi-point source of 75-ns-long probe radiation. The probe radiation pulse is timed near the maximum of e-beam pumping pulse, with the jitter in timing of ≤ 5 ns.

To obtain a transient absorption spectrum, three data runs (spectra) from the CCD array must be known, namely, the spectra of (1) fluorescence of the e-beam-excited gas under study (probe radiation is “shut off”); (2) “input” probe radiation that passed through the unexcited gas (e-beam gun is switched off); and (3) the mixed signal of the fluorescence from and probe radiation passed through the e-beam-excited gas. The fluorescence spectrum signal is subtracted from the mixed signal, giving the “output” probe radiation signal, and the ratio of the output to input probe signals is a wavelength dependence of the transmittance $T(\lambda)$. In acquiring an absorption spectrum, knowing of the relative spectral sensitivity of the recording apparatus is not necessary since all three data runs are recorded with the same spectral response function whose effect is eliminated completely when data runs are divided by each other. Contrary to the case of pure rare gases, in fluorine-containing mixtures e-beam-induced fluorescence is quite a significant. To record it correctly, the relative spectral sensitivity has been measured using a tungsten band-lamp in the visible 350–510 nm spectral range and a deuterium lamp in the UV range. Small nonlinearity of the CCD array response, observed in the calibrating procedure, is taken into account together with relative spectral sensitivity in mathematical treatment of the acquired data. The measured absorption coefficient is determined as

$$k_{meas}(\lambda) = \ln[1/T(\lambda)]/L \quad (1)$$

throughout the spectral range under study, where $T(\lambda)$ is recorded transmittance and $L = 112$ cm is the length of the probe beam path in excited gas. It is time-integrated over the probe pulse duration covering the e-beam pulse and its immediate afterglow. Based on accidental variations of absorption spectra (generally one spectrum was measured 3–5 times), we estimate the measurement accuracy as about 15% for absorption coefficients about $1\text{--}3\text{ m}^{-1}$. Small ($\leq 0.3\text{ m}^{-1}$) and high ($\geq 3\text{ m}^{-1}$) absorption coefficients were measured with worse accuracy.

There are spectral ranges of faulty recording, which are usually hatched in the figures. Those generally appear as absorption valleys related to the line emission in the spectrum of probe radiation and to CCD saturation caused by scattered radiation of the plasma-plume-producing KrF laser and strong fluorescence bands (because of long gas chamber, ArF* and especially KrF* amplified spontaneous emission (ASE) at

$\lambda \sim 193$ and 248 nm, respectively, can be very intense). Note that use of a diffraction spectrometer for recording a panoramic spectrum in which limiting wavelengths differ more than twice suffers an inherent drawback related to second-order recording: in our case, any spectral feature occurring at wavelength $\lambda \leq 255$ nm is to be replicated in the second order. However, use of an appropriate filter (either a HR 248-nm mirror on quartz substrate or a glass plate) set between the gas chamber and spectrometer to suppress the ASE generally eliminates the problem.

3. RESULTS AND DISCUSSION

Experiments are performed in the following order. Fluorine is first added to pure Ar and Kr, to Ar(He, Ne)/Kr mixtures, and then NF₃ is used instead of F₂. Next, nitrogen is added to Ar/Kr/F₂ and to Ar, Kr, and Ar/Kr mixture. The absorption data related to pure rare gases and their binary mixtures presented below in the figures are generally taken from our paper (Levchenko *et al.*, 2010a).

3.1. Binary Rare Gas-Fluorine Mixtures

Both fluorescence and absorption spectra of rare gases change with adding fluorine but, in the case of fluorescence, the change is drastic and related to emission of RgF* and Rg₂F* (Rg is rare gas symbol) excimers, see, e.g., Huestis *et al.* (1984) and Brau (1984).

Adding fluorine to krypton leads, first of all, to strong well-known KrF (*B-X*) emission at $\lambda \sim 248$ nm. Besides, there arise 275-nm KrF (*C-A*) and broad Kr₂F ($4^2\Gamma \rightarrow 1,2^2\Gamma$) bound-free emission bands (Molchanov, 2006; Zvor'ykin, 2007; Huestis *et al.*, 1984; Brau, 1984). The fluorescence spectrum shown in Figure 1a was recorded using a 248-nm broadband cut-off filter, which reduced the magnitude of all KrF fluorescences; nevertheless, 248-nm emission reveals itself in the second order. Kr₂F* emission band has a bell-shaped profile (half-width of about 65 nm) with a maximum at $\lambda \sim 410\text{--}420$ nm. Noticeable self-absorption related to Kr I lines is seen at the red wing of the emission profile. The absorption spectrum of Kr/F₂ mixture shown in Figure 1b is seen to be blue-shifted with respect to the spectrum of Kr₂F* fluorescence and overlapped with it. A blue wing of the recorded fluorescence profile is thus distorted because of volumetric absorption. The fluorescence spectrum has been corrected for volumetric absorption using formula (Shannon *et al.*, 1988)

$$I_{na}(\lambda) = -I_a(\lambda)(\ln[1 - A(\lambda)]/A(\lambda)), \quad (2)$$

where $I_a(\lambda)$ and $A(\lambda)$ are recorded fluorescence and absorption and $I_{na}(\lambda)$ is “true” fluorescence signal that would have been recorded if the absorption had been absent. Corrected fluorescence spectrum $I_{na}(\lambda)$ is shown in Figure 1a; its maximum is just slightly shifted to shorter wavelength compared with the recorded spectrum. The absorption

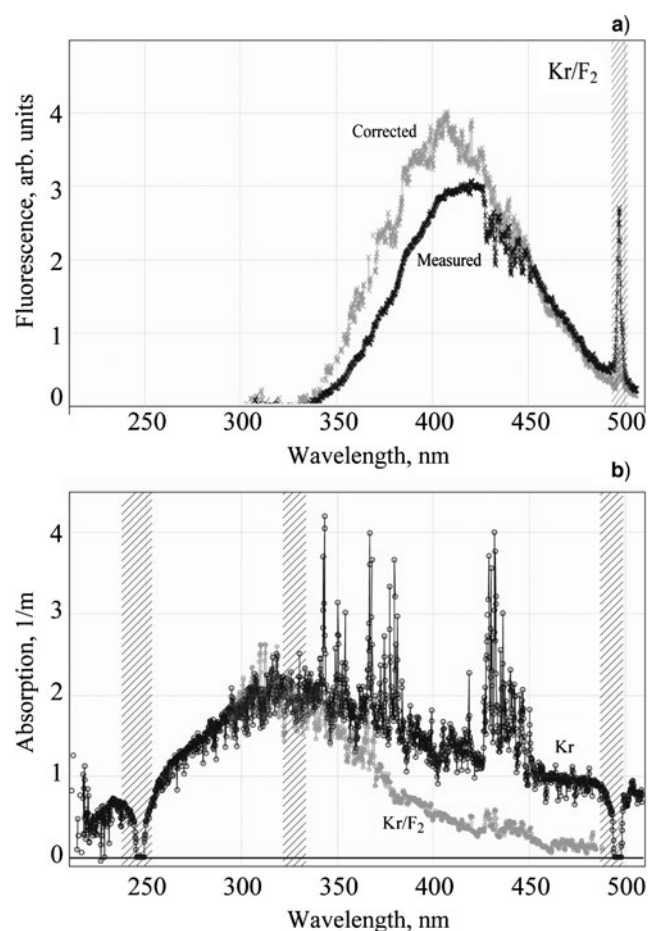


Fig. 1. Spectra of (a) fluorescence (recorded with a broadband 248-nm cut-off filter), measured and corrected for volumetric absorption, and (b) absorption in Kr/F₂ = 99.5/0.5 mixture and in pure Kr at $p = 1.05$ atm.

spectra of Kr/F₂ mixture and pure Kr in Figure 1b are similar in the position of maximum absorption, but different in shape of the long-wavelength tail. Whereas absorbing species in pure Kr is Kr₂⁺ (Levchenko *et al.*, 2010a), in Kr/F₂ mixture there are also Kr₂F* triatomic molecules. UV absorption spectrum of the latter related to (9²Γ ← 4²Γ) transition (as well as all the other spectroscopic properties) was predicted to be very similar to the absorption spectrum of Kr₂⁺ (Wadt & Hay, 1978). Experimental study (Geohegan & Eden, 1988) reported the Kr₂F* absorption profile different from that of Kr₂⁺ within spectral range 335–360 nm. However, more recent study (Schloss *et al.*, 1997) based on monitoring the products of photoabsorption showed the absorption profile similar to that of Kr₂⁺ predicted in (Wadt, 1980) but more narrow, with half-width of about 33 nm. Similarly, in our measurements, the bandwidth of absorption in Kr/F₂ mixture is smaller than in pure Kr. Line absorption referred to Kr* (see Levchenko *et al.* (2010a)) in Kr/F₂ mixture is certainly lower than in pure Kr. As Kr* atoms are mainly produced *via* dissociative recombination of Kr₂⁺ ions, it is reasonable to assume that UV absorption recorded in the

mixture is mainly related to Kr₂F (9²Γ ← 4²Γ) transition rather than to absorption by Kr₂⁺.

Fluorescence spectra of Ar/F₂ mixture at different pressures are shown in Figure 2a. Origin of the fluorescence peaks at 248 nm (497 nm, in the second diffraction order) is caused by traces of Kr in the mixture (KrF (B-X) transition). ArF* is responsible for the fluorescence peak at 193 nm (386 nm). The emission continuum centered at $\lambda \sim 275$ nm shows a broad symmetrical profile with a full width at half maximum (FWHM) of about 60 nm; its blue wing recorded in the second order is seen at the long-wavelength part of the spectral range under study. It is assigned, following literature (e.g., Molchanov (2006) and Marowsky *et al.* (1984)) to Ar₂F fluorescence. We have recorded no broadband emission centered at $\lambda \sim 435$ nm observed in (Sauerbrey *et al.*, 1986) high pressure Ar/F₂ mixtures and ascribed to the four-atomic Ar₃F rare-gas halide complex. It is seen in Figure 2a that pressure dependence of the Ar₂F fluorescence intensity is somewhat non-monotonic: it increases with pressure up to $p \sim 1$ atm, and then slowly decreases up to the highest used pressure of 1.8 atm. Non-monotonic dependence of Ar₂F fluorescence

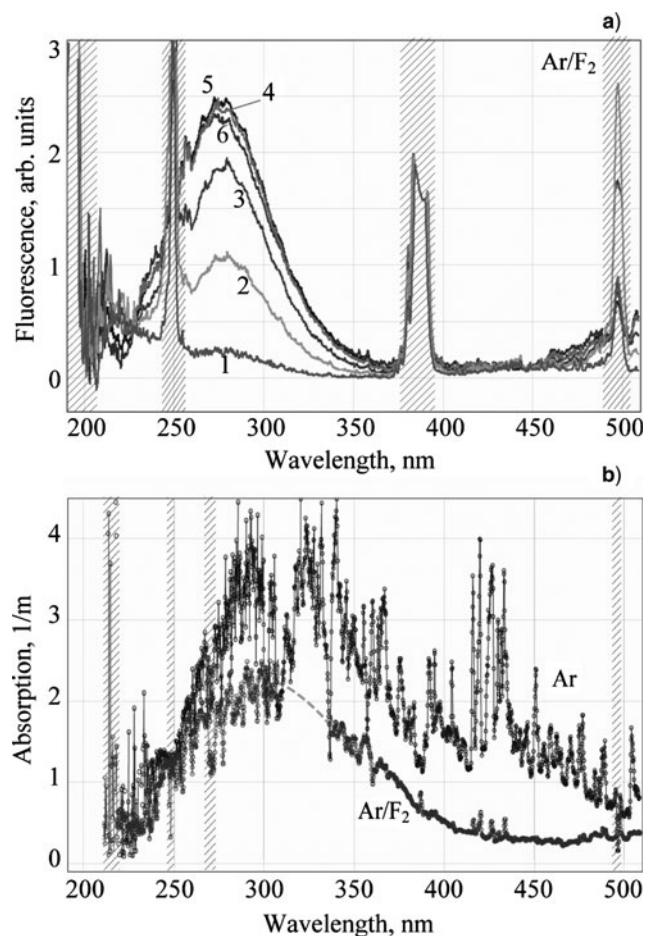


Fig. 2. Spectra of (a) fluorescence from Ar/F₂ = 99.7/0.3 mixture at $p = 0.2$ (1), 0.4 (2), 0.6 (3), 0.8 (4), 1.05 (5), and 1.8 (6) atm and (b) absorption in Ar/F₂ and pure Ar at $p = 1.8$ atm.

on the mixture total pressure p can be extracted from the literature: one can infer from Figure 6a in Marowsky *et al.* (1982) that maximum of Ar_2F fluorescence in $\text{Ar}/\text{F}_2 = 99.7/0.3$ mixture occurs at $p \sim 0.7$ atm, at least in the pressure range 0.5–1.1 atm. The pressure dependence of the 193-nm ArF fluorescence (monitored by an independent photodiode) demonstrates monotonic growth with pressure.

Absorption spectrum of Ar/F_2 mixture shown in Figure 2b is a bell-shaped continuum with half-width of about 120 nm and maximum at $\lambda \sim 300$ nm. It was recorded using a Cu target, and the region of faulty recording around $\lambda \sim 327$ nm (see, Levchenko *et al.* (2010a)) shown by dashed arc is reconstructed. For the sake of direct comparison, Figure 2b also shows absorption spectrum of pure Ar. To our knowledge, no experimental data on UV absorption continuum in Ar/F_2 mixture have been reported in the refereed literature. Our data are in very good agreement with UV absorption spectra presented in the Los Alamos scientific report (Bigio *et al.*, 1990) and ascribed to Ar_2F and Kr_2F ($9^2\Gamma \leftarrow 4^2\Gamma$) transitions. Like in the case of Kr/F_2 , in Ar/F_2 mixture line absorption (by Ar I) and particularly narrow-band absorption corresponding to $\text{Ar}_2^*(n\pi\pi^3\Pi_g) \leftarrow \text{Ar}_2^*(4s\sigma^3\Sigma_u^+)$ (see Levchenko *et al.* (2010a)) transitions are greatly reduced. Consequently, the absorption at $\lambda \sim 325$ nm in the mixture is very unlikely related to photoionization of $\text{Ar}_2^*(4s\sigma^3\Sigma_u^+)$. In view of those reasons, we assign the absorption continuum in Figure 2b mainly to Ar_2F . Contrary to the case of Kr/F_2 mixture, the fluorescence spectrum of Ar_2F is somewhat blue-shifted with respect to the absorption spectrum of Ar_2F , which seems strange at first glance. However, such an opposite behavior was predicted in Wadt and Hay (1978) based on the calculated potential curves. In Wadt and Hay (1978), the predicted maximums of the emission from and absorption by Rg_2F ($4^2\Gamma$) state are, respectively, blue- and red-shifted with regard to those shown in Figures 1 and 2, and so in the case of Ar_2F predicted “opposite shift” between the absorption and fluorescence continuums was even larger than that of about 25 nm seen in Figure 2. In the case of Ar/F_2 mixture, because of closeness of the wavelengths corresponding to the absorption and fluorescence peaks, correcting for volumetric absorption (Eq. (2)) leads to no noticeable wavelength shift of the fluorescence maximum but to increase in its magnitude (approximately two-fold at $p = 1.8$ atm). Since absorption increases with pressure, such correcting eliminates above-mentioned non-monotonicity in the pressure dependence of Ar_2F fluorescence. Under the conditions of present experiments, it is the absorption by Ar_2F which seems to be responsible for absence of lasing on Ar_2F molecule rather than absorption by Ar_2^+ and Ar_2^* claimed in Marowsky *et al.* (1982).

3.2. Ternary Ar(He, Ne)/Kr/F₂ Gas Mixtures

Ternary mixtures of rare gases with fluorine (fluorine donor) are common gain mixtures of rare-gas halide lasers (Molchanov, 1988). Fluorescence and absorption spectra of Ar/Kr/

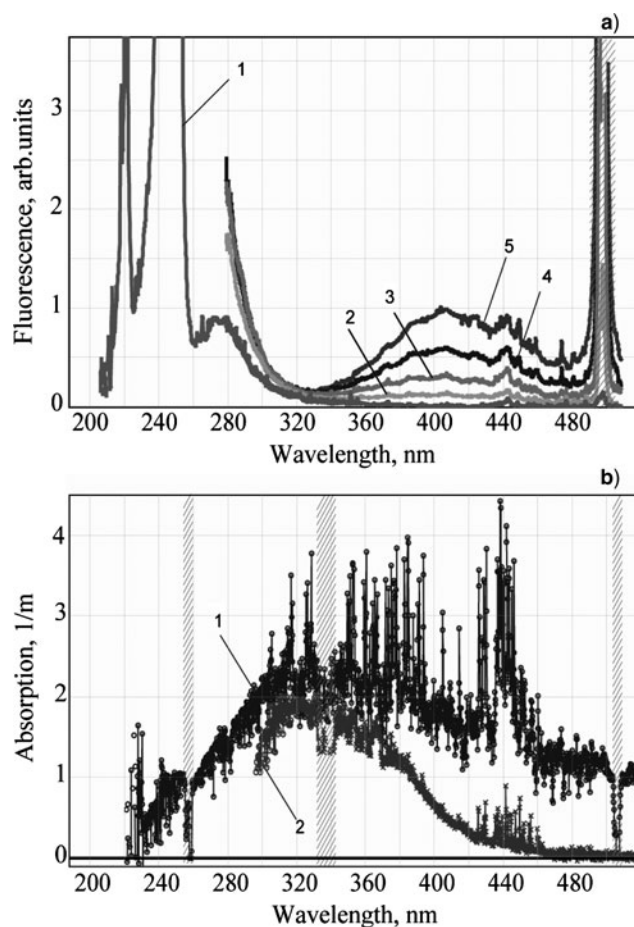


Fig. 3. Spectra of (a) fluorescence from $\text{Ar}/\text{Kr}/\text{F}_2 = 90.7/9/0.3$ mixture at $p = 0.2$ (1), 0.4 (2), 0.8 (3), 1.05 (4), and 1.8 (5) atm (at $p > 0.2$ atm, the short-wavelength side is saturated and not shown) and (b) absorption in $\text{Ar}/\text{Kr} = 91/9$ (1) and $\text{Ar}/\text{Kr}/\text{F}_2$ (2) mixtures at $p = 1.8$ atm.

$\text{F}_2 = 90.7/9/0.3$ mixture, which is a conventional gas mixture of high-power KrF lasers (Zvorykin *et al.*, 2007), are shown in Figure 3. Kr_2F ($4^2\Gamma \rightarrow 1, 2^2\Gamma$) emission band is clearly seen at $p \geq 0.6$ atm. However, at such pressures KrF emission is very strong and must be suppressed with cut-off filter, which makes recording the short-wavelength part of spectrum not possible. The short-wavelength spectrum constituents can be seen at low pressures, when use of the filter is not necessary. One can see in Figure 3a the 220-nm KrF ($D-X$), 248-nm KrF ($B-X$), and 275-nm emission bands. At higher pressures, the 220-nm band is much less intense with respect to the 248-nm band because of strong KrF ($D-B$) collisional quenching. In $\text{Ar}/\text{Kr}/\text{F}_2$ mixture, the 275-nm band is stronger with respect to Kr_2F^* emission than in Kr/F_2 mixture and could be supposed to be a superposition of KrF ($C-A$) and Ar_2F (see Fig. 2a) emission bands. The absorption spectrum of $\text{Ar}/\text{Kr}/\text{F}_2$ mixture is shown in Figure 3b, which also presents absorption spectrum of Ar/Kr mixture. Like in the case of Rg/F_2 mixtures, adding fluorine to Ar/Kr leads to narrowing of absorption profile (~ 90 nm FWHM in $\text{Ar}/\text{Kr}/\text{F}_2$) because of reduction

in the long-wavelength part though maximum at $\lambda \sim 310$ nm remains fairly unchanged. Line absorption gets significantly reduced. However, there is no direct evidence that recorded absorption continuum is related completely to Kr₂F* and in no way to Kr₂⁺. If one adds neon instead of argon as a buffer gas to Kr/F₂ mixture, then there will be no absorption caused by Ne₂⁺ and Kr₂⁺ (Levchenko *et al.*, 2010a). Thus, absorption spectrum of Ne/Kr/F₂ mixture shown in Figure 4a is completely related to Kr₂F* absorber (spectrum of Ne/Kr mixture is also shown in Fig. 4a). Nevertheless, it is not possible to evaluate the magnitude of photoabsorption cross-section like it was done in Levchenko *et al.* (2010a) for Rg₂⁺ absorber in pure rare gas: one has to know both absorber number density and absorption coefficient at some instant. In the case of Kr₂F* absorber, the difference between the measured integral absorption coefficient $k_{meas}(\lambda)$ (Eq. (1)) and peak absorption coefficient $k_{max}(\lambda)$ corresponding to the instant of maximum absorber number density is expected to be less than in pure rare gases (Levchenko *et al.*, 2010a) because of longer lifetime of the absorber. However, to calculate it, as well as the peak absorber number density, one needs to develop a complicated kinetic code, which is not

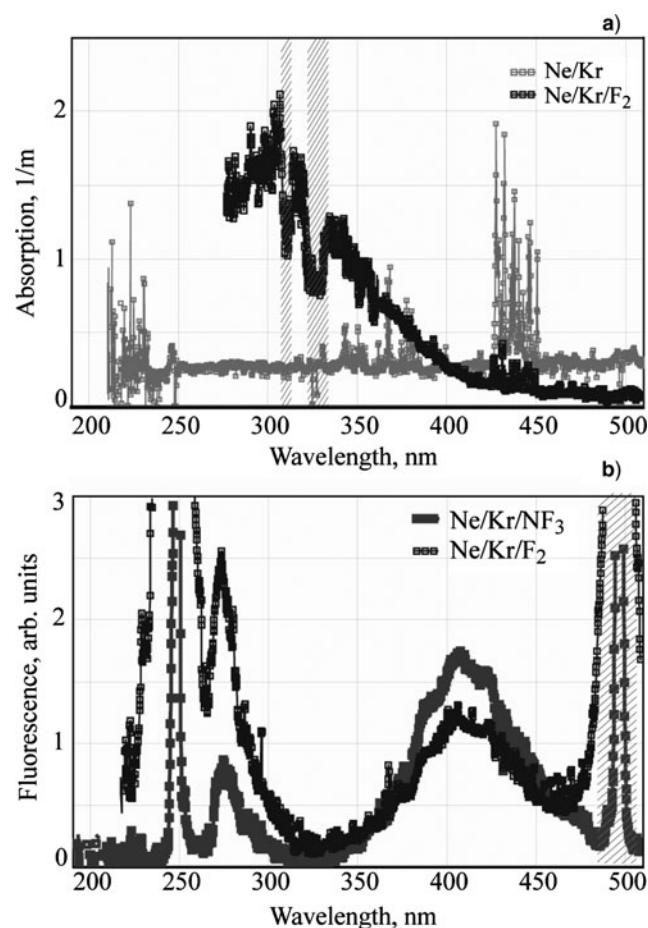


Fig. 4. Spectra of (a) absorption in Ne/Kr = 93.6/6.4 (1) and Ne/Kr/F₂ = 93.4/6.4/0.2 (2) mixtures and (b) fluorescence from Ne/Kr/F₂ (1) and Ne/Kr/NF₃ (2) 93.4/6.4/0.2 mixtures at $p = 2.5$ atm.

possible because of insufficient knowledge of the reaction rate constants in Ne/Kr/F₂ mixture (see, e.g., Section III C in Levchenko *et al.* (2010a)). In Kr/F₂ and Ar/F₂ mixtures, where kinetics is simpler and more thoroughly studied, recorded absorption continuum may contain contribution from another broadband absorber. Besides, because of strong fluorescence in all the mixtures which is subtracted from the measured signal, accuracy in the present absorption measurements is lower than in Levchenko *et al.* (2010a). Comparison of the absorption spectra in Figures 3b and 4a shows that the spectra are fairly similar though that of Ar/Kr/F₂ mixture seems to contain little bit of the absorption by Kr₂⁺. However, one can consider that dominant absorption in Ar/Kr/F₂ mixture is due to Kr₂F ($9^2\Gamma \leftarrow 4^2\Gamma$) transition.

Figure 5 demonstrates virtually linear pressure dependence of the absorption maximum at $p \geq 0.6$ atm. Pressure dependences of the fluorescence at different wavelengths are obtained using appropriate filter set in front of photodiode to select a wavelength of interest. It is seen that pressure dependence of Kr₂F emission is close to quadratic at low pressures, whereas at higher pressures it becomes linear (note that correcting for volumetric absorption hardly changes its slope) and very similar to that of the absorption maximum. Such similarity shows that both fluorescence and absorption maximums are related to the same Kr₂F ($4^2\Gamma$) state. The intensity of KrF (*B-X*) emission band tends to saturate with pressure. The 275-nm emission band shows non-monotonic pressure dependence peaking at $p \sim 0.8$ atm and then significantly decreasing, with specific energy deposition being nearly constant in the pressure range 0.8–1.8 atm (because of backscattering reflector). Adding of Ne to Kr/F₂ mixture leads to great increase in the intensity of 275-nm KrF (*C-A*) fluorescence, with the latter becoming even more intense than 410-nm Kr₂F fluorescence (see Fig. 4b). In Ne/Kr/F₂ mixture, pressure dependence of KrF (*C-A*) emission intensity is similar to that of 275-nm band in Ar/Kr/F₂ mixture. In both cases, correcting for volumetric absorption

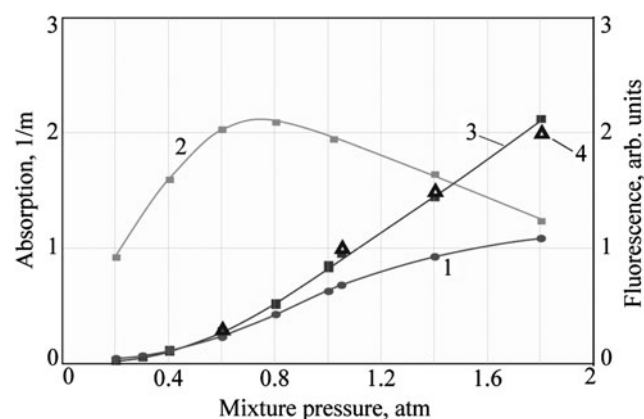


Fig. 5. Absorption at $\lambda \sim 310$ nm (4, triangles) and fluorescence intensity at $\lambda \sim 248$ (1), 275 (2), and 410 nm (3) vs. total pressure of Ar/Kr/F₂ = 90.7/9/0.3 mixture.

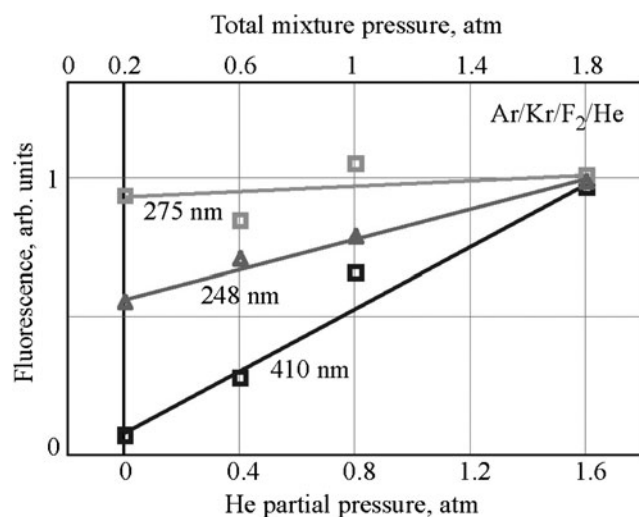


Fig. 6. Fluorescence intensity at $\lambda \sim 248, 275,$ and 410 nm, each normalized to its own maximum intensity at $p = 1.8$ atm, vs. partial pressure of helium added to $\text{Ar/Kr/F}_2 = 90.7/9/0.3$ mixture at $p = 0.2$ atm.

(Eq. (2)) cannot change non-monotonic pressure behavior of the 275-nm fluorescence, unlike the case of Ar_2F fluorescence in Ar/F_2 mixture (see Section 3.1). It is thus likely that in Ar/Kr/F_2 (and obviously in Ne/Kr/F_2) mixture, the 275-nm fluorescence is related rather to KrF (C - A) than to Ar_2F .

In Ar/Kr/F_2 mixture, buffer gas Ar , whose main action is to acquire e-beam energy, also participates as a third body in formation of KrF (via ion branch) and Kr_2F excimers. Another buffer gas can provide different ratio of the reaction rates for such formation. Figure 6 shows behavior of the emission band intensities in Ar/Kr/F_2 mixture at low pressure of 0.2 atm gradually diluted by helium up to the total pressure of 1.8 atm. Taking into account the difference in stopping power of He and Ar , one can see that intensity of the 248-nm emission band increases proportionally to the energy deposition into the $(\text{Ar} + \text{He})/\text{Kr/F}_2$ mixture. The 275-nm emission (recall that the wavelength matches both Ar_2F and KrF (C - A) emission bands) intensity hardly changes with adding He , which can be regarded as an evidence, though indirect, that formation of $\text{KrF}(C)$ via ion branch with He as a third body is inefficient: otherwise one has to assume, contrary to the above, that Ar_2F emission is mainly responsible for the 275-nm emission band in Ar/Kr/F_2 mixture. In contrast, Kr_2F emission intensity (410-nm band) increases greatly with adding helium, in direct proportion to the total pressure of the mixture, whatever the buffer gas.

3.2.1. Recorded absorption and fluorescence profiles in comparison with literature data

The Kr_2F ($9^2\Gamma \leftarrow 4^2\Gamma$) absorption transition is of bound-bound nature. All the six electronic states within the ($4^2\Gamma$, $9^2\Gamma$) segment are strictly bound (~ 2 eV) with respect to $\text{Kr}_2^+ + \text{F}^-$ limits, but only $4^2\Gamma$ is stable with respect to the KrF (D , C , B) + Kr limits (Geohegan & Eden, 1988).

Hence, the states higher than $4^2\Gamma$ can undergo electronic predissociation provided that there is a relevant crossing repulsive potential curve with either of KrF (D , C , B) + Kr limits. The predissociation seems to occur because (1) absorption on Kr_2F ($9^2\Gamma \leftarrow 4^2\Gamma$) transition is followed by KrF (B - X) emission with quite a high quantum yield (Schloss et al., 1997) and (2) no fluorescence or absorption has ever been observed from the Kr_2F electronic states higher than $4^2\Gamma$. Spectral profile of Kr_2F ($9^2\Gamma \leftarrow 4^2\Gamma$) absorption band is predetermined by difference potential between the potential curves of the upper and lower electronic states and Franck-Condon overlap integrals, like in the case of emission spectra (Tellinghuisen, 1982). However, a degree of filling of this feasible profile (in other words, particular width of spectrum) depends on relative population of vibrational levels of the absorbing electronic state. Whereas the first two factors are constant, the latter depends on the excitation and quenching conditions. That can be the reason why the recorded bandwidth of Kr_2F ($9^2\Gamma \leftarrow 4^2\Gamma$) absorption continuum varies from about 33-nm FWHM (optical excitation (Schloss et al., 1997)) to 85-nm FWHM (electric discharge excitation (Greene & McCown, 1989)) and 90-nm FWHM (e-beam excitation, present study). To some extent, the scatter in the measured position of the maximum of Kr_2F ($4^2\Gamma \rightarrow 1,2^2\Gamma$) bound-free fluorescence varying from about 390 nm (Xu et al., 1993) to 420 nm (Huestis et al., 1984) could also be related to that reason. Another reason can be that the fluorescence spectrum is distorted because of volumetric absorption, with the recorded maximum red-shifted with respect to the true (in the absence of absorption) location (see Section 3.1). The shorter the fluorescence/absorption path the smaller the shift (in Xu et al. (1993), the path was as short as about 10 cm). However, correcting for volumetric absorption shifts fluorescence maximum insignificantly even for a fluorescence path of about 1 m (the corrected profile is approximately the same as that shown in Fig. 1a). Note that theoretically predicted Kr_2F fluorescence maximums were at 361 nm ($4^2\Gamma \rightarrow 1^2\Gamma$) and 371 nm ($4^2\Gamma \rightarrow 2^2\Gamma$), with much weaker band at 395 nm ($4^2\Gamma \rightarrow 3^2\Gamma$) (Wadt & Hay, 1978).

3.3. Transformation of Fluorescence and Absorption Spectra of Ar/Kr/F_2 Mixture with Adding Nitrogen or Replacing F_2 by NF_3

3.3.1. $\text{Ar}(\text{Ne})/\text{Kr/NF}_3$ Mixtures

Effect of replacement of F_2 by NF_3 in Ar/Kr/F_2 (as well as in Ne/Kr/F_2) mixture is illustrated in Figures 4b and 7. As a result, Kr_2F fluorescence intensity ($\lambda \sim 410$ nm) increases, whereas KrF emission decreases significantly, as is shown in Figure 4b by the example of fluorescence spectra of $\text{Ne/Kr/F}_2(\text{NF}_3)$ mixtures. Both spectra in Figure 4b were recorded under exactly the same conditions. And, as KrF^* is commonly believed to be a main direct precursor of Kr_2F^* (see, e.g., Rokni & Jacob, 1982), it seems that 248-nm and 410-nm fluorescences should have changed in unison.

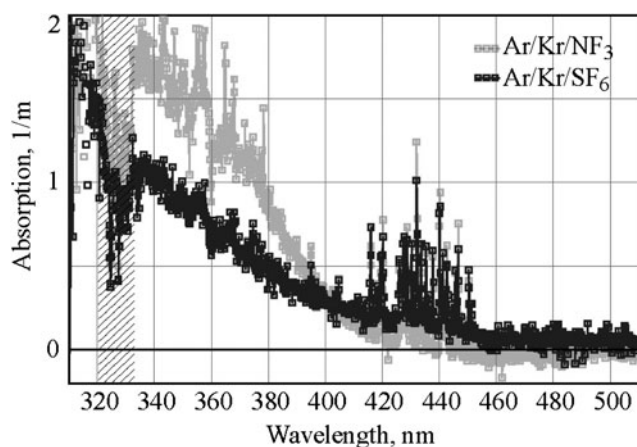


Fig. 7. Absorption spectra of Ar/Kr/NF₃(SF₆) = 90.7/9/0.3 mixtures at $p = 1.8$ atm.

Transient absorption within UV range hardly changes with replacing F₂ by NF₃. However, within the blue spectral range of $\lambda \geq 440$ nm it decreases to such an extent that becomes negative (see Fig. 7) indicating an amplification of the probe signal. A negative absorption as high as -0.05 m^{-1} has been recorded at $\lambda \sim 460$ nm range by optimizing Kr fraction in Ar/Kr/NF₃ mixture.

Why do the mixtures with NF₃ and F₂ behave differently? It was believed for a long time that quenching rates of Kr₂F (4²T) by F₂ and NF₃ were approximately equal (Huestis *et al.*, 1984). More recent measurements (Xu *et al.*, 1993) show that the former is 14 times larger than the latter; moreover, NF₃ quenches KrF(B) 26 times faster than Kr₂F (4²T), whereas the rate constants for quenching those species by F₂ differ by only 2.5 times. However, this difference in the quenching rates cannot be an explanation (at least the only one) for increased Kr₂F fluorescence. We used another fluorine donor, SF₆, with the quenching rate constants even more favorable for Kr₂F emission (quenching rates of Kr₂F (4²T) by SF₆ and F₂ are as 1 to 250 (Xu *et al.*, 1993), but have not obtained the results comparable with NF₃. Fluorescence intensities of both KrF and Kr₂F in Ar/Kr/SF₆ mixture drastically decrease. Both line absorption and UV absorption continuum are lower compared with Ar/Kr/NF₃ mixture but the long-wavelength tail of the continuum does not become negative (see Fig. 7). The rate constant for electron attachment to SF₆ (and hence the production rate for F⁻ ions and the rate of ion channel in formation of KrF) is larger than to F₂. The same was considered to be true for the rate of electron attachment to NF₃ at electron temperatures of 1–2 eV (Chantry, 1982) typical of e-beam-pumped KrF lasers (Brau, 1984). Besides, in contrast to F₂, NF₃ does not absorb KrF 248-nm radiation. Nevertheless, NF₃ (and SF₆ all the more) is less efficient in KrF laser than F₂ (Rokni & Jacob, 1982), despite that ion channel in formation of KrF* is believed to be dominant under e-beam pumping.

In Brau (1984), poor efficiency of NF₃ in KrF laser was explained by decreased rate of neutral channel in production

of KrF* since branching ratio towards KrF* in the harpoon reaction of Kr* with NF₃ is less than for F₂ (0.57 against 1.0, respectively). However, the neutral channel is not dominant under e-beam pumping. Another explanation for poor efficiency of NF₃ is ion-molecular charge transfer from Kr⁺ to NF₃ reducing the production rate for KrF* and producing positive molecular ions to which electrons may combine (Rokni & Jacob, 1982; Boichenko *et al.*, 2000). Note that following the rate constants commonly accepted at that time (Chantry, 1982; Shaw & Jones, 1977), the rate of such charge transfer was to be much smaller than the rate of electron attachment to NF₃. Later measurements (Miller *et al.*, 1995) that the rate constant for electron attachment to NF₃, $(7 \pm 4) \cdot 10^{-12} \text{ cm}^3/\text{s}$ at 300 K, is one and a half orders of magnitude less than that in Chantry (1982) indicate worse efficiency of NF₃ as fluorine donor and support the assumption about relative significance of charge transfer from Kr⁺ to NF₃.

3.3.1.1. Discussion on feasible cause for blue radiation alternative to Kr₂F. Chemistry of the reaction between Kr⁺(Kr*) and NF₃ is complicated and gives rise to various species. One can assume existence in the mixtures with NF₃ of another precursor for Kr₂F (4²T) alternative to KrF*, which is particularly evident in the case of Ne/Kr/NF₃ mixture. Indeed, of all the four possible immediate precursors for Kr₂F* in Ar/Kr/F₂ mixture (KrF*, ArKrF*, Kr₂⁺, and Kr₂* (Boichenko *et al.*, 2000), in order of decreasing importance), only two (KrF* and Kr₂*) are present in Ne/Kr/NF₃ mixture: NeKrF* complex is not known to exist, whereas Kr₂⁺ is absent (see Fig. 4a and Levchenko *et al.* (2010a)). It is known that NF₃-containing mixtures do not recycle (e.g., in XeF laser), which is related to irreversible decomposition of NF₃ in reaction $2\text{NF}_3 \rightarrow \text{N}_2 + 3\text{F}_2$ resulting in formation of some amount of nitrogen (Mandl & Hyman, 1986). Then, e.g., an N₂KrF* excimer (formed via three-body reaction of KrF(B) with nitrogen) can be assumed as one of direct precursors to Kr₂F. In Basov *et al.* (1980) and Zuev *et al.* (1981), N₂KrF* was supposed to be an intermediate stage in formation of Kr₂F and was reported responsible for emission in the range around $\lambda \sim 450$ nm. It is thus possible that increased fluorescence in the blue region could be related not only to Kr₂F. The features discussed seem to be a reason why a gain medium of Kr₂F laser, which operates at $\lambda \sim 435$ nm (Tittel *et al.*, 1980), is Ar/Kr/NF₃ but not Ar/Kr/F₂ mixture. In light of above discussion, it is of necessity to study the effect of adding nitrogen to Ar/Kr/F₂ mixture.

3.3.2. Ar/Kr/F₂/N₂ Mixture

Adding nitrogen to Ar/Kr/F₂ mixture is found to reduce transient absorption, although unequally throughout the spectral range under study. Within quite a broad interval in the range from 410 to 500 nm, it is reduced to a negative value. Figure 8 shows a part of the absorption spectrum of Ar/Kr/F₂ = 90.7/9/0.3 mixture at pressure of 1.7 atm to which 0.08 atm of nitrogen is added. Weak negative

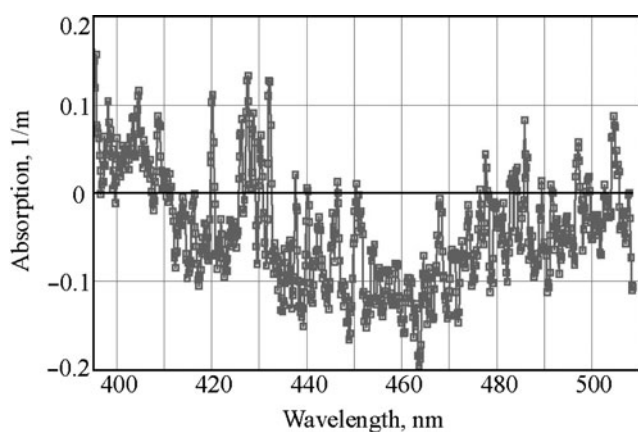


Fig. 8. Part of the absorption spectrum of Ar/Kr/F₂/N₂ mixture at $p \approx 1.78$ atm with N₂ partial pressure of 0.08 atm.

absorption (in other words, amplification) is seen to occur; there are a lot of absorption lines that “notch” and even break the amplification region, especially at the short-wavelength side. The lines are mainly related to Kr I spectral lines but there are also those related to Kr₂* and even to Ar I (e.g., 420.1-nm line) (Levchenko *et al.*, 2010a). The most broad “amplification band” is centered at about 460 nm being red-shifted with respect to the maximum of Kr₂F (4²Γ → 1,2²Γ) fluorescence band. The result of optimization of the amplification magnitude at $\lambda \sim 460$ nm by varying pressure of N₂ additive is shown in Figure 9a. Nitrogen is added to Ar/Kr/F₂ = 90.7/9/0.3 mixture at $p = 1.7$ atm. Particular symbols are related to different measurement runs, which may differ in some experimental features, such as scheme alignment, different optics, etc. Two dashed curves are related to the “most different” data sets. However, all the recorded dependences are “smooth” and show weak amplification in all the measurement runs, so the averaged curve (the solid curve) is expected to reflect the true behavior. The optical gain can be assumed to lie in the range from 0.05 m⁻¹ to 0.15 m⁻¹. Evolution of the 310-nm absorption maximum with adding nitrogen is also shown in Figure 9a. Added nitrogen slightly reduces the width of absorption profile in Ar/Kr/F₂ mixture because of shortening the long-wavelength tail: small additions of nitrogen reduce the long-wavelength 460-nm absorption but hardly affect the absorption maximum, which might be even somewhat increased. The effect of nitrogen upon fluorescence from Ar/Kr/F₂ mixture is illustrated in Figure 9b. Fluorescence intensities at $\lambda \sim 248$ nm (KrF (B-X)) and $\lambda \sim 460$ nm behave quite differently. The 460-nm fluorescence shows local maximum for small nitrogen additive, whereas 248-nm fluorescence monotonically drops with increasing nitrogen pressure.

It is seen from above that both replacing F₂ by NF₃ in and adding small amount of nitrogen to Ar/Kr/F₂ mixture affect the fluorescence and absorption spectra in a similar manner. However, as further increase in the pressure of nitrogen additive leads for a while to increase in the magnitude of negative

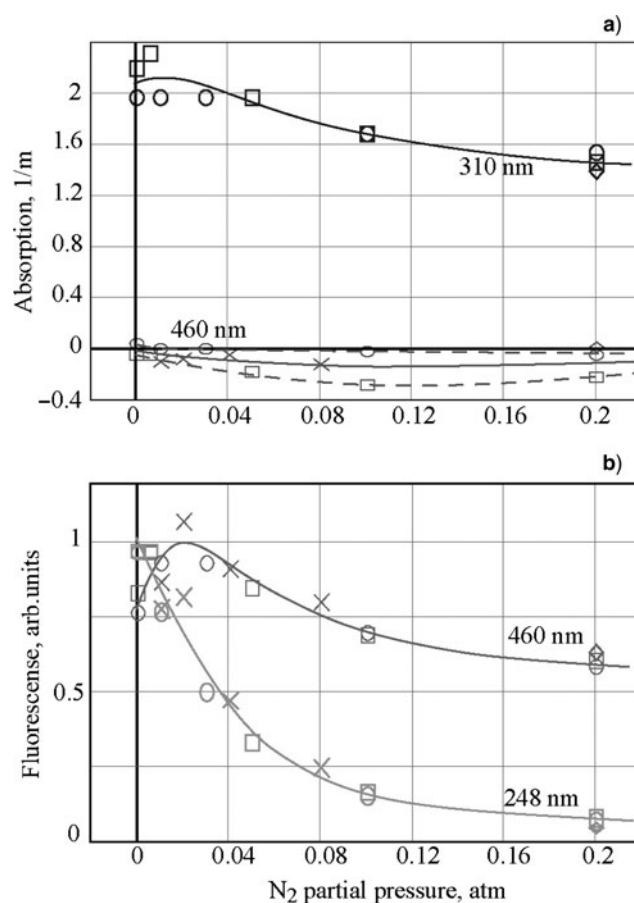


Fig. 9. Absorption (a) and fluorescence (b) in Ar/Kr/F₂ = 90.7/9/0.3 mixture at $p = 1.7$ atm at wavelengths of (a) 310 and 460 nm and (b) 248 and 460 nm vs. pressure of nitrogen added to the mixture. Different symbols correspond to different measurement runs.

absorption, 460-nm fluorescence intensity begins to decrease, and maximum amplification in the blue spectral range is reached when fluorescence has already dropped below initial level. Hence, there has to be another reason for increasing negative absorption in the blue range different from hypothetical amplification by N₂KrF* or some other nitrogen-containing species. Note also that 410-nm fluorescence related only to Kr₂F (4²Γ → 1,2²Γ) transition behaves with adding nitrogen similarly to 460-nm fluorescence. There are some obvious effects of adding nitrogen to Ar/Kr/F₂ mixture related to that nitrogen is efficient vibrational relaxant. First, it is significant decrease in electron temperature in the course of electron-impact vibrational excitation of N₂ molecule, to the value of a few tenths of an eV (Sauerbrey *et al.*, 1982). Since the dependence of the rate constant for electron attachment to F₂ on electron temperature is monotonically declining (Chantry, 1982), there is to occur an increase in the electron attachment rate constant. However, like in the case of replacing F₂ by NF₃, such increase is followed by decrease in KrF* number density. Apparently, electron attachment to F₂ is a dominant process of electron loss both with and without N₂ additive. Irrelevance of the

increased rate of electron attachment for enhanced formation of Kr₂F has also been demonstrated above by the example of SF₆-containing mixtures. Another effect of adding nitrogen is efficient vibrational-vibrational (VV) relaxation of excited molecules, particularly Kr₂F, in the collisions with nitrogen. Both fluorescence and absorption at $\lambda \sim 460$ nm are related to Kr₂F (4²T) but to different ν levels. Taking into account that absorption peak is much farther from 460 nm than fluorescence maximum, it is reasonable to assume that, in the case of absorption, ν is higher. Vibrational relaxation will then reduce absorption rather than fluorescence, and the gain can exceed the absorption loss at $\lambda \sim 460$ nm.

3.3.2.1. Comparison with literature data on Ar/Xe/CCl₄/N₂ mixture. Somewhat similar situation was observed for e-beam-excited Ar/Xe/CCl₄ high-pressure mixture (Sauerbrey *et al.*, 1982) where adding nitrogen led to increase in the output energy of Xe₂Cl laser ($\lambda \sim 515$ nm). Like in our case of Ar/Kr/F₂ mixture, the rate constant for electron attachment to CCl₄ halogen donor greatly increased with adding nitrogen though fluorescence of XeCl* (a precursor to Xe₂Cl*) decreased. However, the intensity of Xe₂Cl* fluorescence was relatively insensitive to addition of nitrogen over a broad range of N₂ partial pressure. It was said (Sauerbrey *et al.*, 1982) that production rate of Xe₂Cl* is not affected by N₂ but modeling showed that number densities of the absorbing species Xe*, Xe₂⁺ and presumably Xe₂* (the latter is misprinted in Sauerbrey *et al.* (1982)) decrease with nitrogen. This reduced absorption was assumed to be responsible for increasing output of Xe₂Cl laser. Let us note that, in the case of Xe₂Cl*, self-absorption seems to be insignificant: the absorption and emission profiles related to Xe₂Cl(4²T) are more separated than those of Kr₂F(4²T). The reason is that Xe₂Cl* absorption is significantly blue-shifted with respect to Xe₂⁺ 1(1/2)_u → 2(1/2)_g UV absorption (McCown *et al.*, 1985), whereas absorption profiles of Rg₂F* species are similar to those of Rg₂⁺ (see, e.g., Section 3.1).

Taking into account complicated kinetics in Ar/Kr/F₂/N₂ gas mixture, it seems to be of interest to examine transient absorption in the mixtures of argon and krypton with nitrogen.

3.4. Ar/N₂, Kr/N₂ and Ar/Kr/N₂ Mixtures

In the spectral range under study, no measurable fluorescence was observed in e-beam excited Ar, Kr, and Ar/Kr gas mixture (Levchenko *et al.*, 2010a). However, even small additive of nitrogen to argon leads to origin of strong well-known fluorescence corresponding to (0 → 0), (0 → 1), and (0 → 2) $\nu' \rightarrow \nu''$ transitions of the second positive band system C³Π_u → B³Π_g of molecular nitrogen (Pressley, 1971; Ernst *et al.*, 1979) centered at 337.1, 357.7, and 380.5 nm, respectively. In our experiments, the 357.7-nm emission line is much stronger than the others, which disagrees with early observations of the spontaneous emission from e-beam-excited Ar/N₂ mixtures that intensities of 337.1-nm and

357.7-nm emission lines are nearly equal (Ernst *et al.*, 1979). The energy is known to be transferred from metastable Ar atoms to N₂ via resonant reaction



When nitrogen is added to pure Kr or Ar/Kr mixture, no fluorescence is detected (more exactly, it is within the noise level, if any). Indeed, it is known from the literature (Levchenko *et al.*, 2010a; Brau, 1984) that, in Ar/Kr mixture with minor additive of Kr, excitation is efficiently transferred from argon (mainly from atomic and molecular ions) to krypton with subsequent production of Kr* (5s). The energy of Kr*(5s) levels is lower than that of Ar*(4s) levels, and

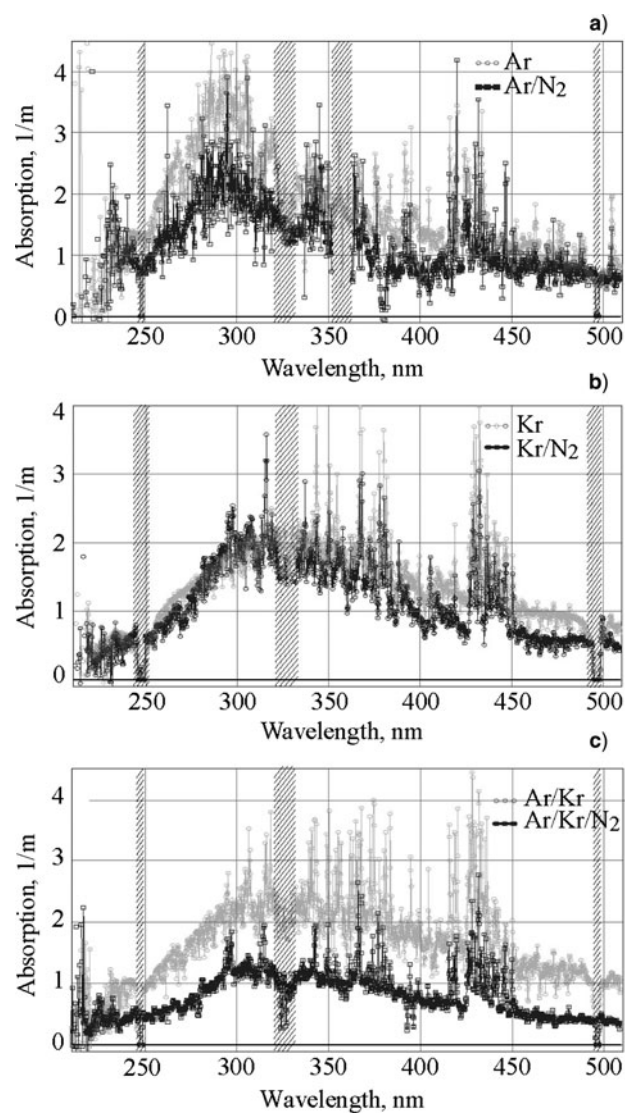
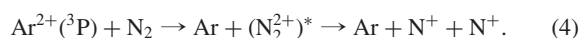


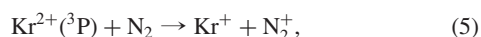
Fig. 10. Absorption spectra in (a) pure Ar and Ar/N₂ = 1.75/0.05 mixture at $p = 1.8$ atm, (b) pure Kr and Kr/N₂ = 0.95/0.1 mixture at $p = 1.05$ atm, and (c) Ar/Kr = 1.64/0.16 and Ar/Kr/N₂ = 1.6/0.16/0.05 mixtures at $p = 1.8$ atm.

energy transfer to nitrogen in reaction of type (3) becomes impossible.

Absorption spectra of the mixtures with nitrogen show some interesting features (see Fig. 10). Already small addition of nitrogen (in amount of about 3%) to argon leads to significant decrease in the absorption maximum at 295 nm (related to Ar_2^+ (Levchenko *et al.*, 2010a)). That is surprising taking into account that the energy transfer is believed to go *via* reaction (3) and $\text{Ar}^*(4s)$ is produced after dissociative recombination of Ar_2^+ . In other words, loss of $\text{Ar}^*(4s)$ is not to affect the number density of higher-energy Ar_2^+ . Unfortunately, the spectra have been recorded using a Cu target and thus the absorption peak at 325 nm related to Ar_2^* is not seen in pure Ar (Fig. 10a). Because strong 357.7-nm emission saturates the CCD, absorption around 357.7 nm in Ar/ N_2 mixture is not as well represented in Figure 10a. Note that 325-nm peak is to be decreased with nitrogen because reaction (3) reduces number density of the atomic precursor for Ar_2^* . Contrary to the case of argon, even rather significant addition of nitrogen (in amount of about 10%) to krypton does not affect the absorption maximum although somewhat reduces its long-wavelength fraction (Fig. 10b). Similarity (both in the shape and magnitude), between the absorption spectra of pure Kr and Ar/Kr mixture was discussed in detail in (Levchenko *et al.*, 2010a): in both cases, absorption is caused by Kr_2^+ ions. It is however seen in Figure 10c that even small ($\sim 3\%$) addition of nitrogen to Ar/Kr mixture significantly reduces (approximately halves) the absorption. Further increase in nitrogen number density (up to about 17% of the total pressure) does not significantly affect the absorption. On comparing Figures 10a, 10b, and 10c, one has to assume that, besides well-known reaction (3), nitrogen “captures” excitation from high-lying energy states of argon. We may suggest it occurs *via* reaction (Smith *et al.*, 1980)



in which nitrogen “seizes” all the charge from doubly charged Ar^{2+} ions, which are produced in e-beam-excited argon in a noticeable amount (Langhoff, 1994). Such ions finally convert into Ar_2^+ and Ar^+ ions (Wieser *et al.*, 2000) with the latter, in turn, converting into Ar_2^+ ions. The rate of the energy transfer to nitrogen seems to be high enough for nitrogen added in amount of about 3% apparently depletes high-lying energy reservoir ($\text{Ar}^{2+}(^3\text{P})$ in (4)) as further increase in nitrogen pressure causes only slight effect. Contrary to the case of Ar/ N_2 mixture, reaction of less energetic Kr^{2+} ions with nitrogen is known to proceed exclusively *via* single charge (electron) transfer (Smith *et al.*, 1980)



and thus does not lead to equally drastic reduction in Kr_2^+ number density; however, it should be somewhat decreased. Nitrogen is known to reduce the intensity of the second

emission continuum (145 nm) related to Kr_2^* (Kanaev *et al.*, 1993): then, one could have supposed that the long-wavelength fraction of the absorption continuum decreasing with nitrogen was related to Kr_2^* . However, in Ne/Kr mixtures, there is no continuous absorption at all whereas absorption related to $\text{Kr}^*(5s)$ is definitely present (see Fig. 4a and Levchenko *et al.* (2010a)). Absolute concentration of Kr is not small, and as long as there are $\text{Kr}^*(5s)$ atoms, there also have to be Kr_2^* dimers responsible for the emission in the second continuum. Hence, whole 320-nm absorption continuum is caused by only Kr_2^+ ; its absorption maximum and long-wavelength fraction are related, respectively, to low- ν and high- ν states of Kr_2^+ (see Levchenko *et al.* (2010a)) with the latter being collisionally quenched by N_2 . Such collisional quenching enlarges population of low- ν levels and increases 320-nm absorption, which might compensate the reduction in the production rate of Kr_2^+ due to reaction (5). As a result, there is no noticeable decrease in the maximum of continuum absorption with adding nitrogen to Kr. Similarly, observed reduction in the absorption at $\lambda \sim 460$ nm in Ar/Kr/ F_2 / N_2 mixture can be caused by enhanced vibrational relaxation of Kr_2F ($4^2\Gamma$, $\nu > 0$). In the light of above, one can expect that, after adding nitrogen to Kr/ F_2 mixture, spurious transfer of energy to nitrogen reducing excitation rate will be minimal whereas collisional quenching of vibrationally excited Kr_2F is to proceed.

4. CONCLUSION

Transient absorption has been measured with the novel erosion-plasma-source probe technique in a broad spectral range 190–510 nm for Ar(He, Ne)/Kr/ NF_3 ($\text{F}_2 + \text{N}_2$) gas mixtures under e-beam excitation rate of 1 MW/cm³ typical of rare-gas halide laser operation. It is experimentally observed that, in Kr/ F_2 and Ar/ F_2 mixtures, fluorescence and absorption spectra of Rg_2F species are shifted with respect to each other in the opposite direction. Continuous absorption spectrum of Ar_2F excimer is reported, as far as we know, for the first time in the refereed literature. Strong overlapping between the fluorescence and absorption spectra of Ar_2F is responsible for the absence of lasing on Ar_2F molecule. Absorption spectrum of Kr_2F excimer is recorded in pure form using a Ne/Kr/ F_2 mixture with no alternative broadband absorber. It is found that minor additive of nitrogen to Ar/Kr/ F_2 mixture or use of NF_3 instead of F_2 reduces transient absorption in the blue range and results in broadband optical amplification centered at about 460 nm. Both amplification by nitrogen-containing species (e.g., N_2KrF^*) and nitrogen-caused enhancement of vibrational relaxation in Kr_2F ($4^2\Gamma$), reducing population of the absorbing states, can be the reason. The maximum amplification is estimated as $\sim 0.1 \pm 0.05 \text{ m}^{-1}$. Further experiments with improved accuracy were performed in seven-pass scheme with Ar/Kr/ NF_3 mixture using a 25-ns-long (FWHM) narrow-band probe pulse of dye laser at $\lambda \sim 460$ nm (Levchenko *et al.*, 2010c). By varying the time delay of the probe pulse with

respect to the beginning of e-beam pumping, it was demonstrated that maximum gain of 0.1 m⁻¹ occurs at time delay about 100 ns, which corresponds to maximum fluorescence of Kr₂F. Such gain is high enough to amplify femtosecond laser pulses in a muti-pass amplifier layout.

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